Fabrication and Electrical Characterization of Al/Ba$_x$Sr$_{1-x}$TiO$_3$/Pt/SiO$_2$/Si Configuration for FeFET Applications

Ala’eddin A. Saif, Z. A. Z. Jamal, Z. Sauli, P. Poopalan

Abstract—The ferroelectric behavior of barium strontium titanate (BST) in thin film form has been investigated in order to study the possibility of using BST for ferroelectric gate-field effect transistor (FeFET) for memory devices application. BST thin films have been fabricated as Al/BST/Pt/SiO$_2$/Si-gate configuration. The variation of the dielectric constant ($\varepsilon$) and tan $\delta$ with frequency have been studied to ensure the dielectric quality of the material. The results show that at low frequencies, $\varepsilon$ increases as the Ba content increases, whereas at high frequencies, it shows the opposite variation, which is attributed to the dipole dynamics. tan $\delta$ shows low values with a peak at the mid-frequency range. The ferroelectric behavior of the Al/BST/Pt/SiO$_2$/Si has been investigated using C-V characteristics. The results show that the strength of the ferroelectric hysteresis loop increases as the Ba content increases; this is attributed to the grain size and dipole dynamics effect.

Keywords—BST thin film, Electrical properties, Ferroelectric hysteresis, Ferroelectric FET.

I. INTRODUCTION

For the past few years, ferroelectric random access memories (FRAMs) have attracted much attention due to their potential advantages as nonvolatile, unlimited write cycles and low power consumption. In particular, nondestructive read out (NDR) FRAM which has a transistor as a memory cell is attractive, since the ferroelectric gate offers simpler circuits and excellent performances [1], [2]. In general, there are two types of ferroelectric field effect transistors (FeFET); metal-ferroelectric-semiconductor (MFS) FET and Metal-ferroelectric-metal-insulator-semiconductor (MFMIS) FET. In fact, the latter consists of a ferroelectric capacitor and a conventional MOSFET. Due to the remnant polarization of the ferroelectric materials, the retained charges at the bottom electrode of the capacitor are coupled to the semiconductor and the conducting channel is then induced to allow the current flowing through drain to source.

Barium strontium titanate (Ba$_{1-x}$Sr$_x$TiO$_3$), or BST, in thin film form is considered one of the most leading candidates for ferroelectric field effect transistor (FeFET) application due to the desirable properties such as high permittivity and relatively high remnant polarization. BST is a solid solution prepared solutions for the solution can be found somewhere else [7], [8]. The prepared solutions were consecutively named BST50, BST70 and BST80. These solutions were deposited on the Pt/SiO$_2$/Si substrate, using the film fabrication procedures reported in [7] and [8]. In order to measure the films thickness, the films were partially dipped in a diluted hydrofluoric acid (HF); the resulting step-profile thickness was measured with a stylus profilometer. The average thickness of the prepared films is measured to be 450 nm. The crystallization of the films has been determined using an X-Ray diffractometer (XRD) with a CuK$_\alpha$ radiation source ($\lambda = 1.54$ Å), and operated at a voltage of 40 KV and a current of 40 mA. For the electrical measurement, dots of Al with an area of $7.85\times10^{-3}$ cm$^2$ were deposited on top of the films through a shadow mask using a physical vapor deposition (PVD) technique to represent the top electrode. Thus, the electrical measurements were carried out on Al/BST/Pt/SiO$_2$/Si (MFMIS) structures. The dielectric characteristics were performed by an impedance/gain-phase analyzer (Solartron 1260) in the frequency range of 10 Hz to 1 MHz at room temperature. The capacitance-voltage (C-V) and the current-voltage (I-V) curves were measured using Keithley 4200 semiconductor parameter analyzer.

III. RESULTS AND DISCUSSION

A. XRD Analysis

Fig. 1 shows the X-ray diffraction patterns of BST50, BST70 and BST80 films. It can be observed from the figure...
that the diffraction peaks are (1 0 0), (1 1 0), (1 1 1), (2 0 0), (2 1 0) and (2 1 1) within the 20 range from 20° to 60°, which confirms that the films are crystallized with the Perovskite structure. The measured lattice parameters of the samples are listed in Table 1. It is observed that the lattice parameters decrease with the increasing strontium content. This decrease can be explained according to the fact that as Sr\(^{2+}\) ions are substitutionally on the Ba\(^{2+}\) site; consequently, as the Sr content increases, a small decrease in the unit cell volume takes place [8].

<table>
<thead>
<tr>
<th>Sample</th>
<th>a (Å)</th>
<th>c (Å)</th>
<th>c/a</th>
<th>Structure phase</th>
</tr>
</thead>
<tbody>
<tr>
<td>BST50</td>
<td>3.9471</td>
<td>3.9471</td>
<td>1</td>
<td>Simple cubic</td>
</tr>
<tr>
<td>BST70</td>
<td>3.9771</td>
<td>3.9883</td>
<td>1.003</td>
<td>Tetragonal</td>
</tr>
<tr>
<td>BST80</td>
<td>3.9785</td>
<td>4.0173</td>
<td>1.0098</td>
<td>Tetragonal</td>
</tr>
</tbody>
</table>

B. Electric and Ferroelectric Characteristics

Fig. 2 shows the variation of \(\varepsilon\) with frequency for various Ba:Sr ratio at room temperature. From Fig. 2, it can be seen that at low frequencies, the value of \(\varepsilon\) increases as the Ba content increases. This can be explained according to the lattice shape and the presence of the dipoles in the BST lattice. It is discussed earlier in this article that BST70 and BST80 films are crystallized in a tetragonal phase which leads that their lattice contains a valuable number of permanent dipoles whereas BST50 lacks to this kind of dipoles since it is crystallize with a cubic phase. That explains the high value of dielectric constant for BST70 and BST80 films compared to BST50. Furthermore, the high value of \(\varepsilon\) for BST80 compared to BST70 can be attributed to the longer permanent dipoles, since the c/a ratio for BST80 is larger than that for BST70.

On the other hand, at high frequencies, the dielectric constant variation with Ba content becomes the opposite of that observed at low frequencies; i.e. \(\varepsilon\) decreases as the Ba content increases. This may be explained considering the dipole elongation responding to the applied electric field. As an AC electric field is applied at BST lattice, it creates a new dipoles, reorients the permanent dipoles to the direction of the applied field and causes an induced shift to the Ti ions for the dipoles that are already have the same orientation of the applied field and causes an induced shift to the Ti ions for the dipoles that are already have the same orientation of the applied field in case of BST70 and BST80 films, which in turn increases their length. However, as the frequency increases, the longer dipoles find it harder to follow the applied field, as a result, a low dielectric constant is obtained. Furthermore, the trend of \(\varepsilon\) at high frequencies agrees very well with the published results in the literature [3]. The value of \(\varepsilon\) in the whole frequency range is relatively high.

The variation of tan \(\delta\) as a function of frequency is given in Fig. 3. It can be observed from the figure that at low frequencies tan \(\delta\) decreases with increasing frequency and reaches a value close to zero at high frequencies. At a frequency range between 250 to 10\(^3\) Hz, a broad peak in BST70 and BST80 is observed. This kind of peak occurs when the hopping frequency of electric charge carriers

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approximately equal to that of the external applied AC electric field [10], however, this peak becomes more noticeable and shifts toward lower frequencies as the Ba content increases. This could be attributed to the increase of the grain sizes and dipoles present. From the above results it can be concluded that the dielectric properties of the films used in this work are relatively good.

The ferroelectric properties for the films used in this work were performed using the capacitance-voltage (C-V) characteristics technique. Fig. 4 shows the C-V characteristics for BST50, BST70 and BST80 at 500 KHz and at room temperature. The capacitance was measured while a DC field was swept from -7.5 to +7.5 V and then reversed, with a sweeping rate of 0.01 V/s. For all the tested samples, it is observed that the capacitance varies non-linearly with the applied voltage. However, a well-defined butterfly shape with two peaks of the capacitance is observed, these peaks are formed as a result of a spontaneous polarization switching. This kind of hysteresis indicates that these films have a ferroelectric nature. However, the hysteresis loop for the current samples resembles to the memory window for MFIS configuration.

It can be observed from the figure that the hysteresis loop strength increases as the Ba content increases. This increment is attributed to the permanent dipoles present and grain size effects. XRD analysis reveals that BST70 and BST80 films crystallize with a tetragonal structure while BST50 crystallized with a cubic structure, which leads to the valuable number of permanent dipoles that exist within the Perovskite lattice of BST70 and BST80; these dipoles contribute to the ferroelectric behavior subsequently at the hysteresis loop strength. On the other hand, the increment of the hysteresis loop strength can be explained based on the grain size effect. It has been found in previous work that the grain size of BST increases with the increasing of the Ba content [8]. However, it is mentioned earlier in this article that the ferroelectric properties, such as remnant polarization and coercive field, strongly depend on the grain size. In addition, G. Arlt et al. presented theoretical calculations showing that the density of the domain walls is inversely proportional to the square root of the grain size [11], i.e., the density of the domain walls increases as the grain size decreases. This in turn strengthens
the repulsive force between neighboring domain walls. As a result, the mobility for the domain wall reduces, which in turn makes the domain reorientation more difficult [12]. Leading up to higher activation energy is required for the reorientation of the domains; as a result, the remnant polarization decreases, which in turn reflects as a strong hysteresis loop in C-V curves.

Furthermore, an observed asymmetry in the C-V curves suggests that the films contain mobile ions or charges accumulated at the interface between the film and the electrode. In addition, there is a difference between the capacitance values of the two peaks, which may be due to some defect in energy levels in the films [13].

A typical variation of leakage current density as a function of applied voltage (J-V) for the films used in this work, at room temperature, and for positive voltage swept from zero up to 8 V is shown in Fig. 5. It is observed that the leakage current density increases with the increase of the applied voltage, and it is found that for all the tested samples the leakage current density is of the order of $10^{-7}$ A/cm$^2$ at an applied voltage of 8 V (0.2 MV/cm). These values of the current density are relatively low, leading to good interface situations. Furthermore, it is observed that the leakage current density decreases as the Ba content decreases, which is attributed to the decrease of the grain size. It is well-known that the grain boundaries act as trappers for crystal defects (vacancies and dislocations) that interact with free carriers. Furthermore, as the grain size decreases the density of the grain boundaries increase, which leads to larger amount of vacancies and dislocations, giving rise to high density local charge accumulation. Those charge centers near the grain boundaries act to block the current flow, leading to low leakage current.

![Fig. 5 Leakage current density for various Ba: Sr ratios at room temperature.](image)

**IV. CONCLUSION**

Perovskit-type BST thin films have been successfully fabricated as MFMIS configuration. The quality of the films has been confirmed via investigation the variation of the dielectric constant ($\varepsilon$) and tan $\delta$ as a function of frequency. The results show that at low frequencies, $\varepsilon$ increases as the Ba content increases, whereas at high frequencies, it shows the opposite variation, which is attributed to the dipole dynamics. Tan $\delta$ shows low values with a peak at the mid-frequency range. The ferroelectric behavior of the films has been investigated using C-V characteristics. The results show that the strength of the ferroelectric hysteresis increases as the Ba content increases; this is attributed to the grain size and dipole dynamics effect. The formation of the hysteresis loop for the films in the current work leads that BST in thin film form can be used for ferroelectric field effect transistor applications.

**REFERENCES**


